# Counterbalancing iridium coating stress for astronomical X-ray mirrors



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#### Agenda:

- Programmatic context
- Requirements for mirror coatings
- Experimental set-up
- The challenge of coating stress
- Measured iridium coating stress
- Stress compensation by SiO<sub>2</sub>
- Stress compensation by Cr layer
- Summary and Outlook

#### **Programmatic context**



The coating development at Aschaffenburg University is embedded in international collaborations with groups from other universities and institutes. For the results of the TRILAMICO-F project presented here bi-national funding by the Bavarian-French Academic Centre BFHZ has been granted.



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## **Introduction: New technology needed**



# Next generation X-ray observatories require:

- apertures of several meters
- large effective areas
- good angular resolution
- stringent mass budgets



Previously used mirror technologies are not able to fulfil the challenging requirements of future X-ray telescopes.

→ Development of new technologies for X-ray mirrors is needed.





#### **Wolter-I design:** Curved mirrors integrated in nested coaxial shells



#### This design is followed up by the Max-Planck-Institute for extraterrestrial physics. Substrates of mirror segments are formed by indirect hot slumping of thin glass sheets.





#### **Lobster-Eye design:** Flat silicon wafer substrates



This design is followed up by our partners of CVUT Prague. In a bionic approach the mirror arrangement adopts the focusing principle of a lobster eye.

#### **Requirements for X-ray mirror coatings**

General requirements for grazing incidence X-ray mirrors coatings are:

- high X-ray reflectivity
   → high-Z coating materials (→ Ir)
   → low roughness and high density
- no mirror shape deformation introduced by the coating
   → low coating stress
- no degradation of the mirrors during storage and in space
- coating process suitable for serial production

Iridium coated X-ray mirror







#### **Experimental set-up**



**Sputtering chamber** 

Schematic set-up

Aschaffenburg University is using sputtering equipment for the coating development of iridium reflection layers for X-ray mirrors. The Institut Fresnel has similar - more industrial - equipment.

## The challenge of coating stress





Micrograph with stress induced cracks in Ir - monolayer



Micrograph of a Cr/Ir – bilayer without cracks

Iridium layers often suffer from high coating stress. In extreme cases, high stress levels can induce cracking or even delamination of the Ir coatings. The application of a thin Cr adhesion layer can overcome this problem.

# Substrate material for stress evaluation



In the presented approach the substrate material (only) for the stress evaluation is the well-known material fused silica:

Diameter of substrate:  $D_s = 25 \text{ mm}$ Thickness of substrate:  $t_s = 1.00 \pm 0.05 \text{ mm}$ Young modulus:  $E_s = 73 \text{ GPa}$ Poisson coefficient:  $v_s = 0.16$ Flatness:  $\approx \lambda/4$  @ 532 nm



#### **Stress measurement**



The change in the substrate radius of curvature was measured with two white-light interferometers. Thereby the cross-calibrated results of Aschaffenburg University and of Institut Fresnel are consistent.



Mechanical coating stress is calculated from substrate radius of curvature change before  $(R_s)$  and after  $(R_{s+f})$  deposition using the Stoney equation, given here for a single layer coating with thickness  $t_f$ 

$$\sigma = \frac{E_{S} t_{S}^{2}}{6t_{f} (1 - v_{S})} \left( \frac{1}{R_{S+f}} - \frac{1}{R_{S}} \right)$$

### **Iridium coating stress**





#### A linear relation is expected between the K<sub>s</sub>/R<sub>norm</sub> ratio and the film thickness t<sub>f</sub> Measured iridium coating stress (slope): about -1870 MPa

#### **Stress compensation by backside coating**





#### **Stress compensation by backside coating**





# A coating of the substrates backside with a thickness adapted $SiO_2$ layer is able to compensate the coating stress of the reflecting iridium layer.

# Variation of chromium thickness





# An intermediate chromium layer with adapted thickness is able to compensate the coating stress of a 30 nm thick reflecting iridium layer.

#### **Summary and Outlook**

- Programmatic context of TRILAMICO-F.
- Requirements for X-ray mirror coatings.
- Challenge of low stress iridium layers.
- Intermediate chromium adhesion layer are needed for proper iridium coatings.
- Backside coatings of SiO<sub>2</sub> are able to compensate the iridium coating stress.
- An adapted chromium layer thickness is able to compensate the high iridium coating stress.

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#### Thank you for your attention.

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